In the ~~Claims:~~

1(currently amended): A reduced glare, conductive coated panel comprising:

a transparent substrate having a first surface and a second surface;

a first, multilayer stack disposed on said first surface of said substrate, said first stack comprising at least a ~~plurality of~~ first transparent, thin film layer, a second transparent, thin film layer and a third transparent, thin film ~~layers~~ layer;

a second, multilayer stack disposed on said second surface of said substrate, said second stack comprising at least a ~~plurality of~~ first transparent, thin film layer, a second transparent, thin film layer and a third transparent, thin film ~~layers~~ layer;

each thin film layer in said first stack having a corresponding thin film layer in said second stack;

each of said transparent, thin film layers of said first stack having a refractive index, said first transparent, thin film layer of said first stack being disposed on said first surface of said substrate, said second transparent, thin film layer of said first stack being disposed on said first thin film layer of said first stack, and said third transparent, thin film layer of said first stack being disposed on said second thin film layer of said first stack;

each transparent, thin film layer of said second stack having the refractive index of its corresponding transparent, thin film layer of said first stack; said first transparent, thin film layer of said second stack being disposed on said second surface of said substrate, said second transparent, thin film layer of said second stack being disposed on said first thin film layer of said second stack, and said third transparent, thin film layer of said second stack being disposed on said second thin film layer of said second stack;

the film thickness of any one of said thin film layers of said second stack being different than the thickness of ~~said~~ its corresponding thin film layer of said first stack;

at least one of said thin film layers of said first stack having a thickness greater than the thickness of ~~said~~ its corresponding thin film layer of said second stack;

the material composition of said corresponding layers in each of said first and second stacks being the same; the refractive index of each of said second thin film layers in said first and second stacks being greater than the refractive index of the other thin film layers in said first and second stacks; the refractive index of said third thin film layer in each of said first and second stacks being less than the refractive index of the other thin film layers in said first and second stacks;

~~said first stack comprising an outermost thin film layer spaced farthest away from said first surface;~~

a transparent conductive thin film on said ~~outermost~~ third thin film layer of said first stack, said transparent conductive thin film comprising a material selected from at least one of indium tin oxide, doped tin oxide, and doped zinc oxide; and

whereby visible light transmission through said coated panel is increased as compared to said substrate coated only with said transparent conductive thin film.

2 (original): The coated panel of claim 1 wherein said transparent substrate is glass.

3 (original): The coated panel of claim 1 wherein said transparent substrate is selected from the group consisting of glass and plastic.

4-7 (canceled)

8 (currently amended): The coated panel of claim ~~6~~ 1 wherein said first layers in each of said first and second stacks are formed from a combination of silicon dioxide and titanium dioxide, each of said first layers having a refractive index at the sodium D line in the range of from about 1.5 to about 2.0.

9 (currently amended): The coated panel of claim ~~6~~ 1 wherein said second layers in each of said first and second stacks are formed from titanium dioxide, said second layers each having a refractive index at the sodium D line of at least about 2.0.

10 (currently amended): The coated panel of claim ~~6~~ 1 wherein said third layers in each of said first and second stacks are formed from silicon dioxide, said third layers each having a refractive index at the sodium D line of less than about 1.5.

11-14 (canceled)

15 (currently amended): The coated panel of claim 1 wherein said second stack comprises ~~an outermost thin film layer spaced farthest from said second surface; and~~ a transparent

conductive thin film on said ~~outermost~~ third thin film layer of said second stack, said transparent conductive thin film on said second stack being selected from at least one of indium tin oxide, doped tin oxide, and doped zinc oxide.

16 (canceled)

17 (original): The coated panel of claim 1 wherein each of said layers of said first stack has a thickness greater than the thickness of said corresponding layer of said second stack on said second surface.

18 (currently amended): A reduced glare, conductive coated panel comprising:

a transparent substrate having a first surface and a second surface;

a first, transparent, interference thin film disposed on said first surface of said substrate;

a second, transparent, interference thin film disposed on said second surface of said substrate;

said first thin film corresponding to but having a thickness ~~different from~~ greater than said second thin film;

a third thin film disposed on said first thin film and a fourth thin film disposed on said second thin film, said third thin film corresponding to but having a thickness greater than said fourth thin film;

a fifth thin film disposed on said third thin film and a sixth thin film disposed on said fourth thin film, said fifth thin film corresponding to but having a thickness greater than said sixth thin film;

the material composition of each of said ~~first~~ corresponding thin ~~film~~ films being the same ~~as the material composition of said second thin film~~; and

a transparent conductive coating on said ~~first~~ fifth thin film, said transparent conductive coating being selected from at least one of indium tin oxide, doped tin oxide, and doped zinc oxide;

each of said first, second, third, fourth, fifth and sixth thin films having a refractive index, the refractive index of said third and fourth thin films being greater than the refractive

index of the other thin films, said refractive index of the fifth and sixth thin films being less than the refractive index of the other thin films; and

whereby visible light transmission through said coated panel is increased compared to said substrate coated only with said transparent conductive coating.

19-24 (canceled)

25 (currently amended): The coated panel of claim ~~23 wherein~~ 18 also including said transparent conductive coating ~~is~~ on said sixth thin film.

26-33 (canceled)

34-50 (withdrawn)

51-52 (canceled)

53 (new): The coated panel of claim 8 wherein said second layers in each of said first and second stacks are formed from titanium dioxide, said second layers each having a refractive index at the sodium D line of at least about 2.0.

54 (new): The coated panel of claim 53 wherein said third layers in each of said first and second stacks are formed from silicon dioxide, said third layers each having a refractive index at the sodium D line of less than about 1.5.